

Hematite Photoelectrodes Review
&
Scope of Plasmonic Photoelectrodes
for splitting water

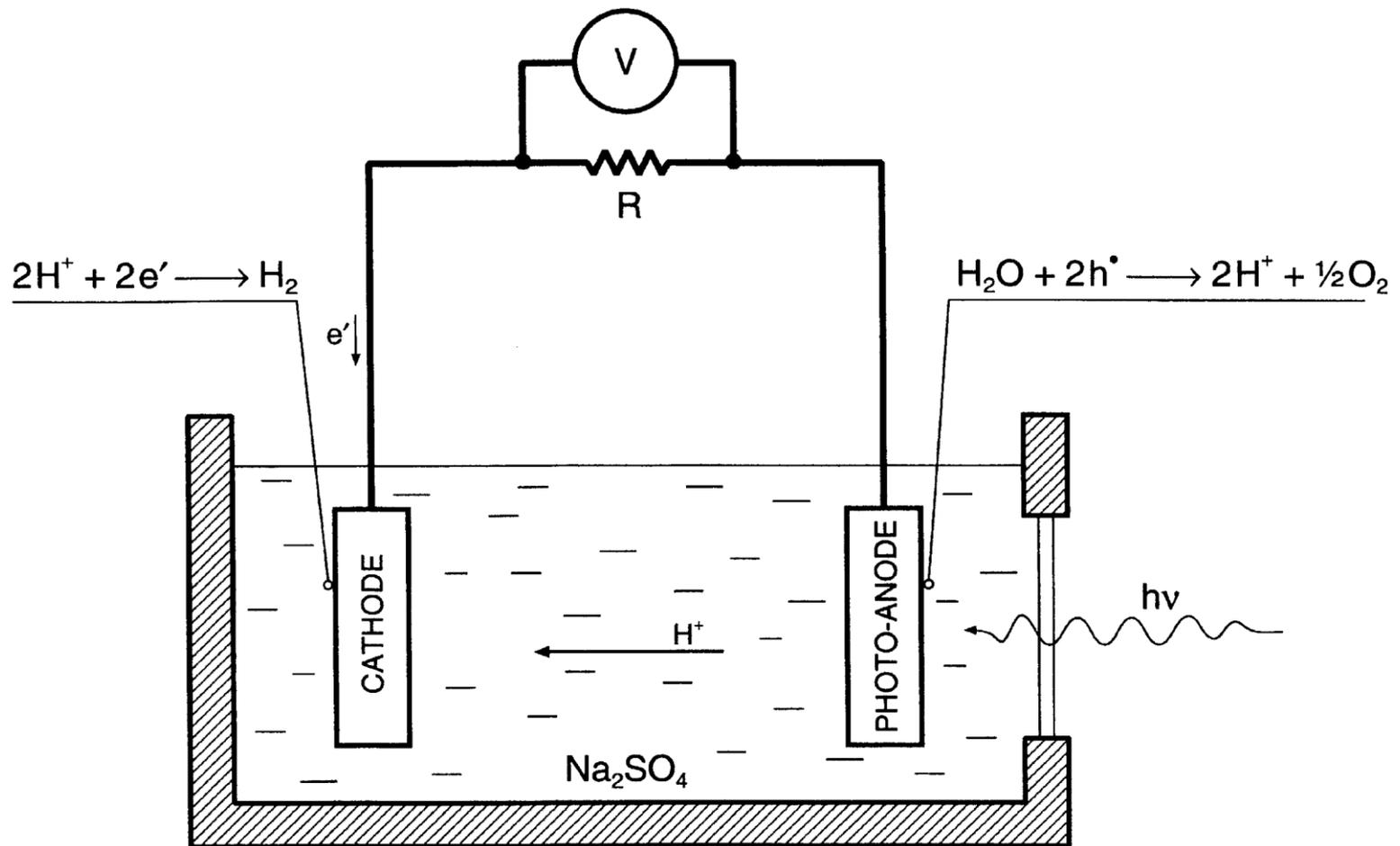
Sarath Ramadurgam

09/18/2013

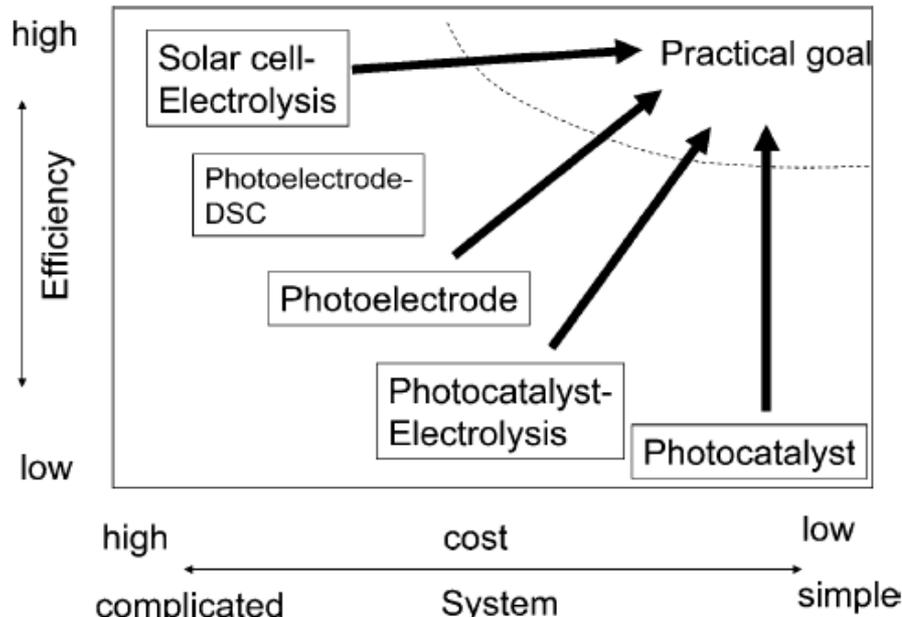
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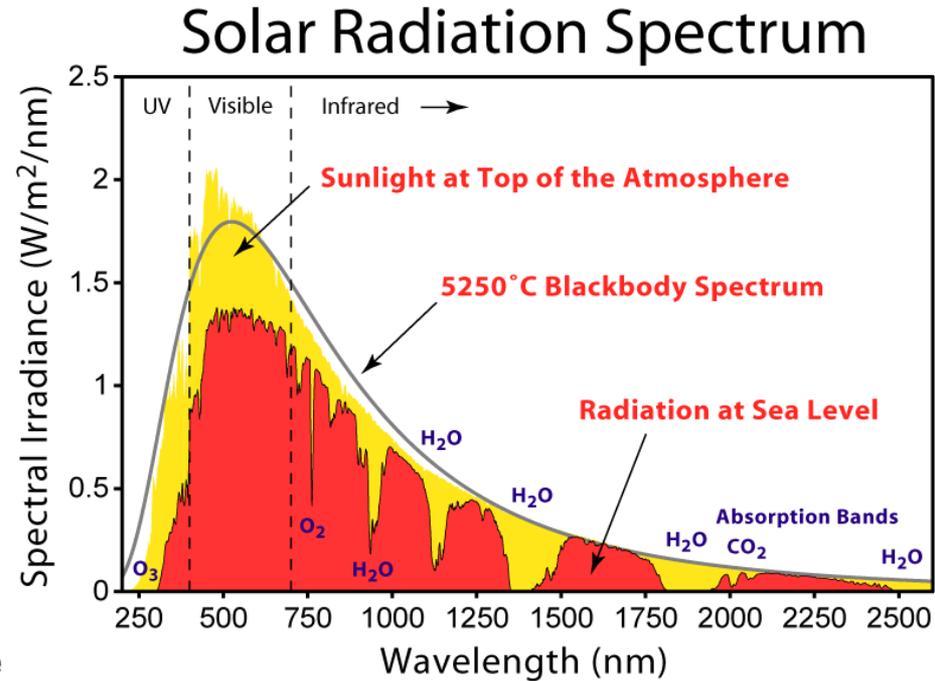
Photo-electrochemical Cell



Benchmark for photoelectrodes



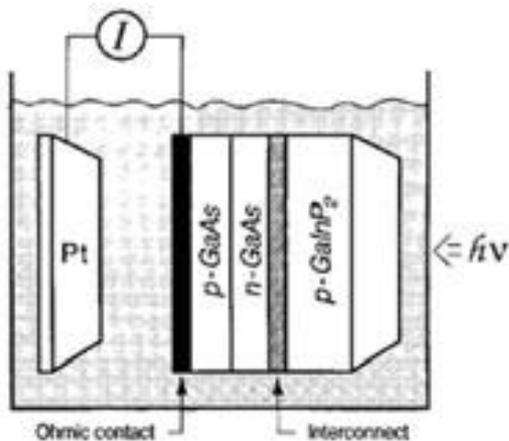
Krol, Gratzel, Springer, 2012



- Energy required for electrolysis of water ~ 1.23 eV which corresponds to 1006 nm.

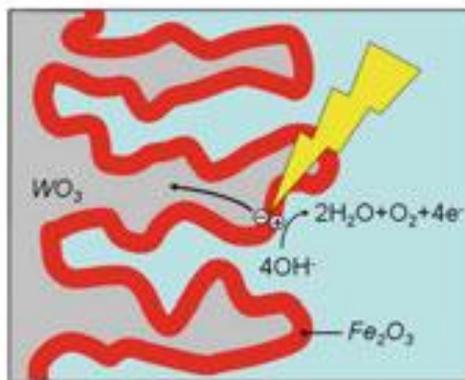
Benchmark for photoelectrodes

Monolithic PV+Electrolysis



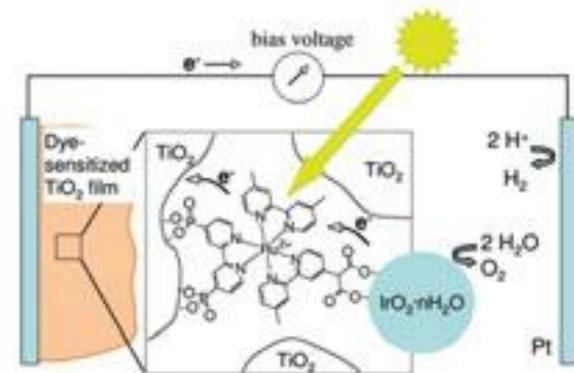
10-15%

Metal Oxide Photoelectrodes



3-5%

Molecular/Hybrid Systems



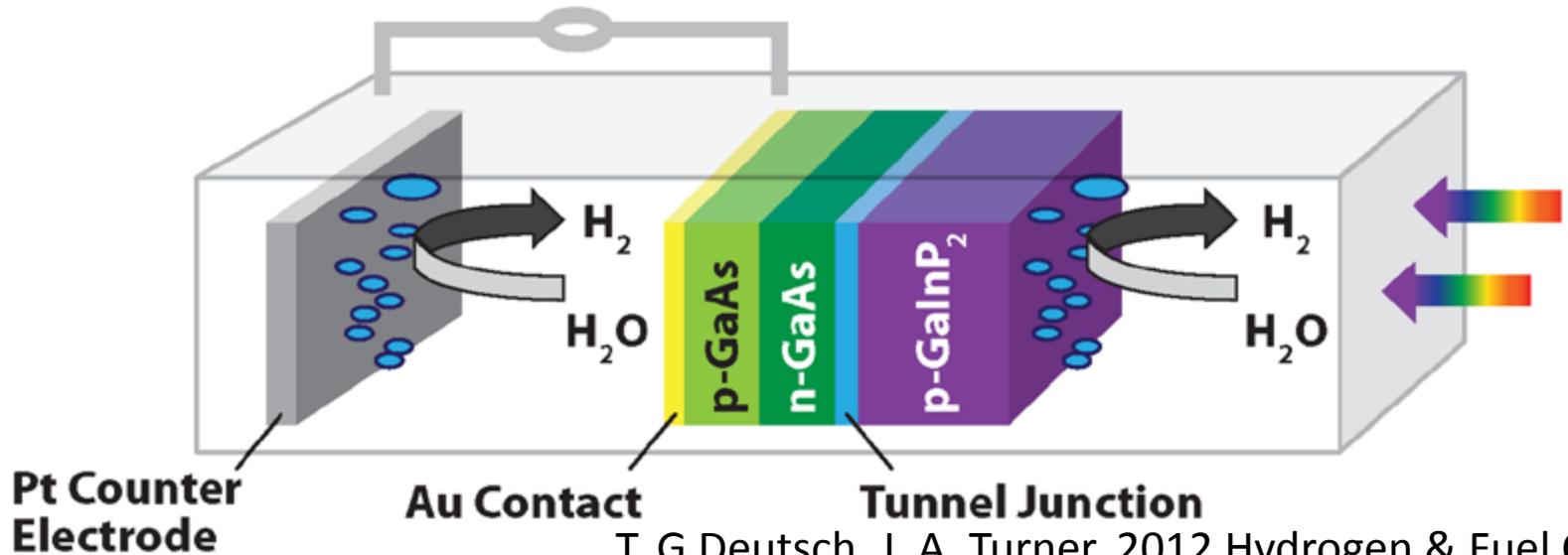
< 1%

Proven efficiencies

Krol, Gratzel, Springer, 2012

Low cost

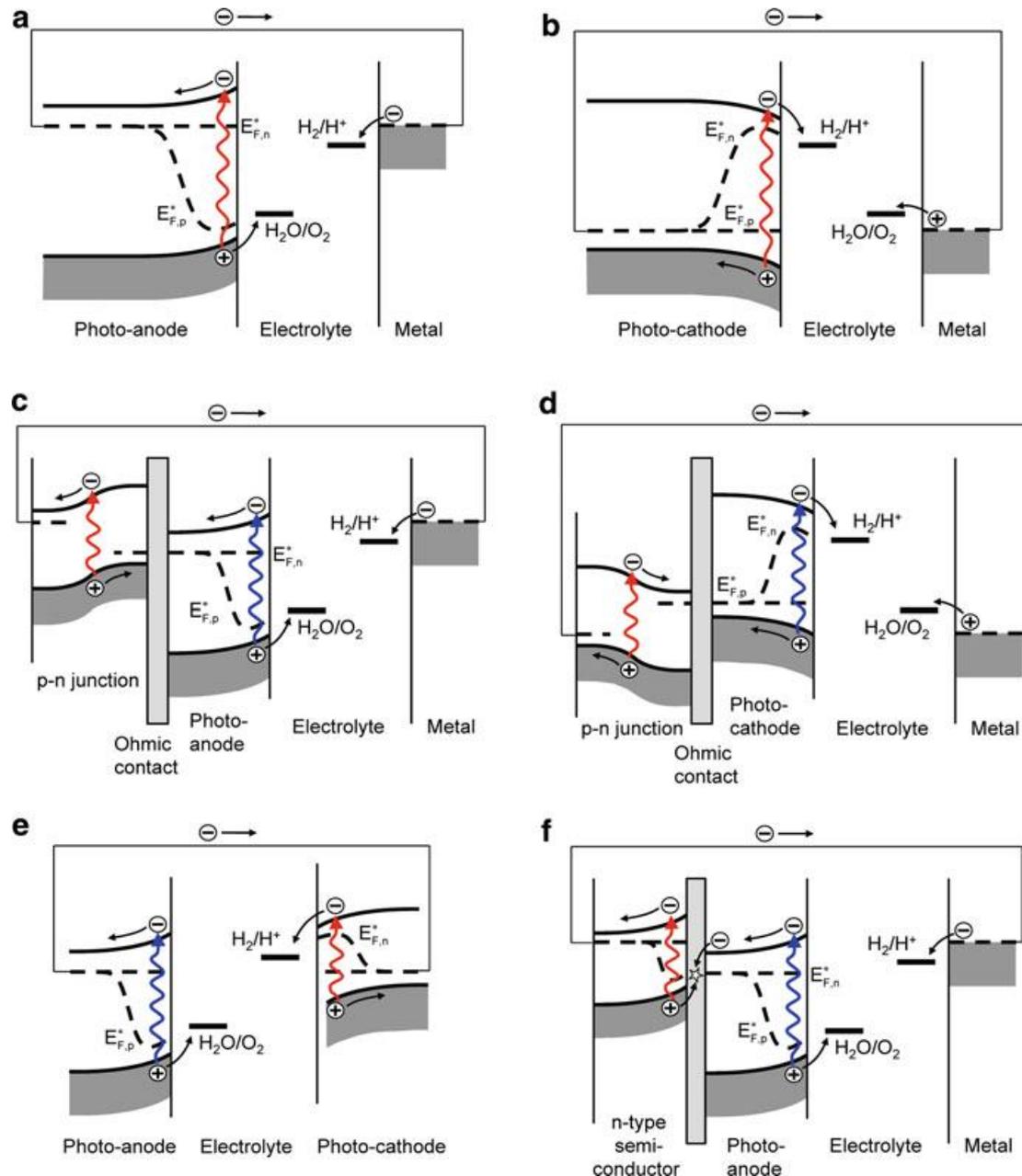
Benchmark for photoelectrodes



T. G Deutsch, J. A. Turner, 2012 Hydrogen & Fuel Cells Program review, NREL.

- Efficiency $\sim 12.4\%$
- Nitride passivated surface achieved over 100+ hours of undamaged operation

Photo-electrochemical cell designs



Krol, Gratzel,
Springer,
2012

Photoelectrode requirements



Good visible light absorption

- 1.23 eV – minimum photon energy for splitting water
- Bandgap – 1.9-3.1 eV

Chemical stability

- Stable in electrolyte
- No Photo-corrosion

Band edge positions

- Band gap straddles the oxidation and reduction potentials for water.

Efficient charge transport

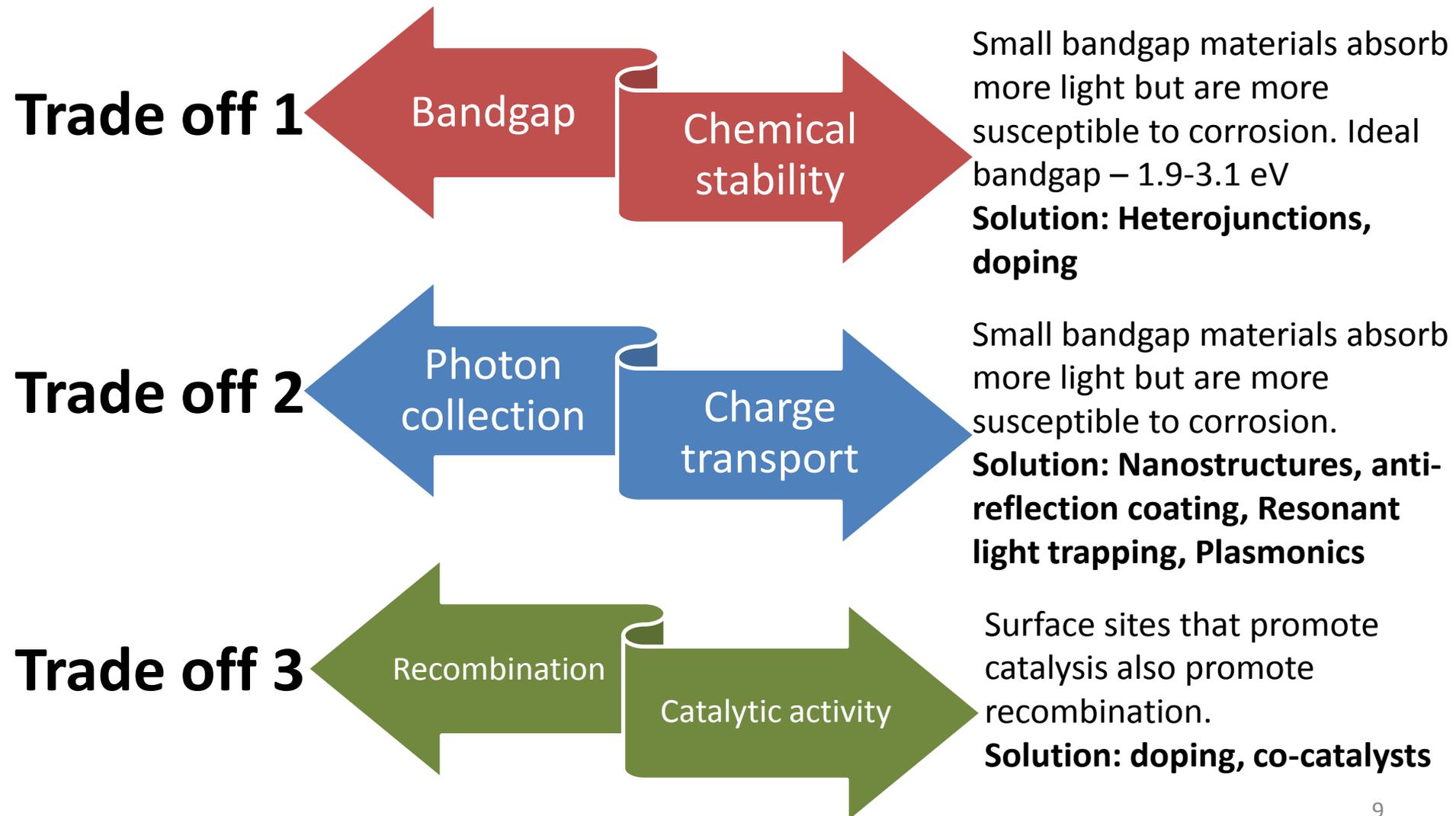
- Reduced recombination.

Low overpotential

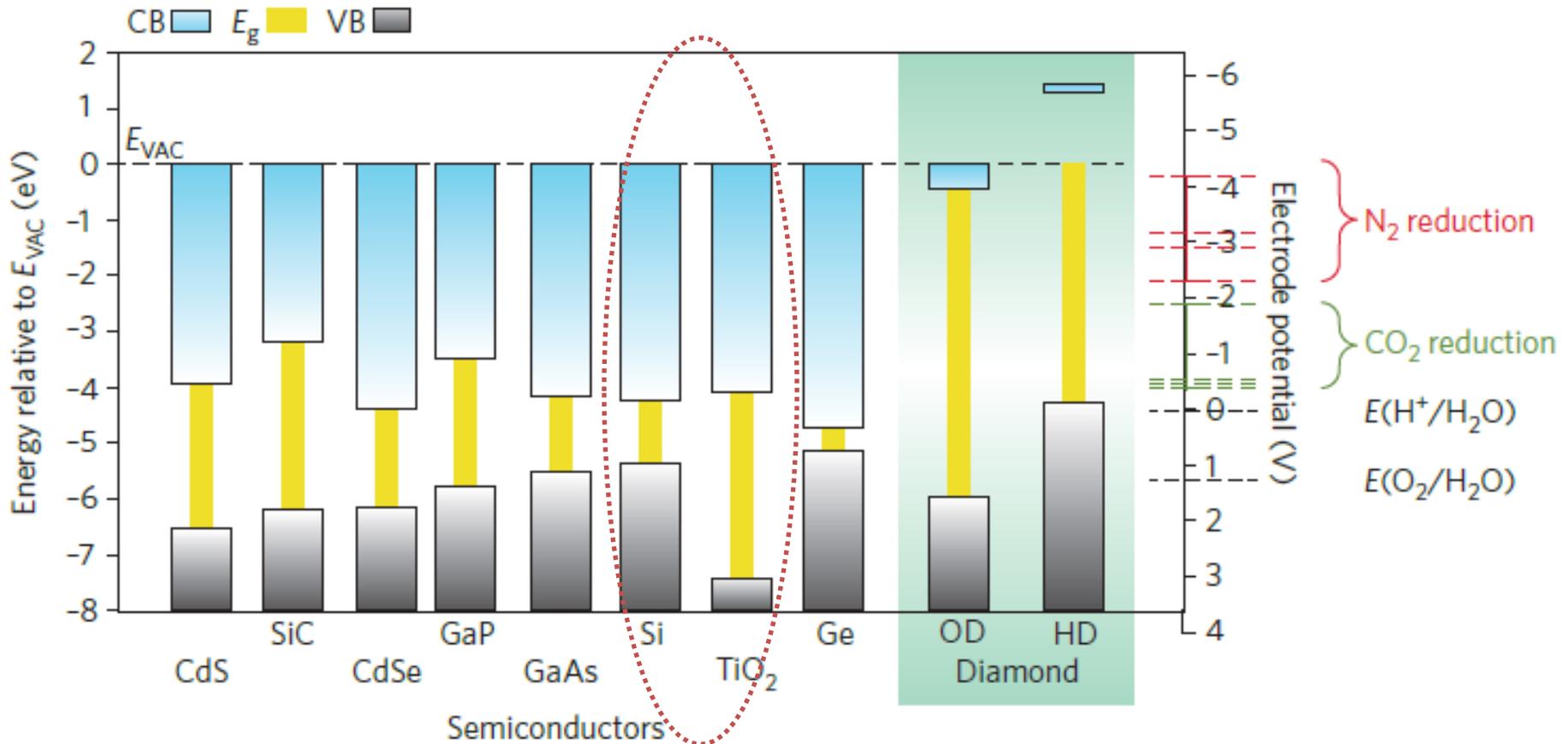
- Lower implies lesser energy photons required

Low cost

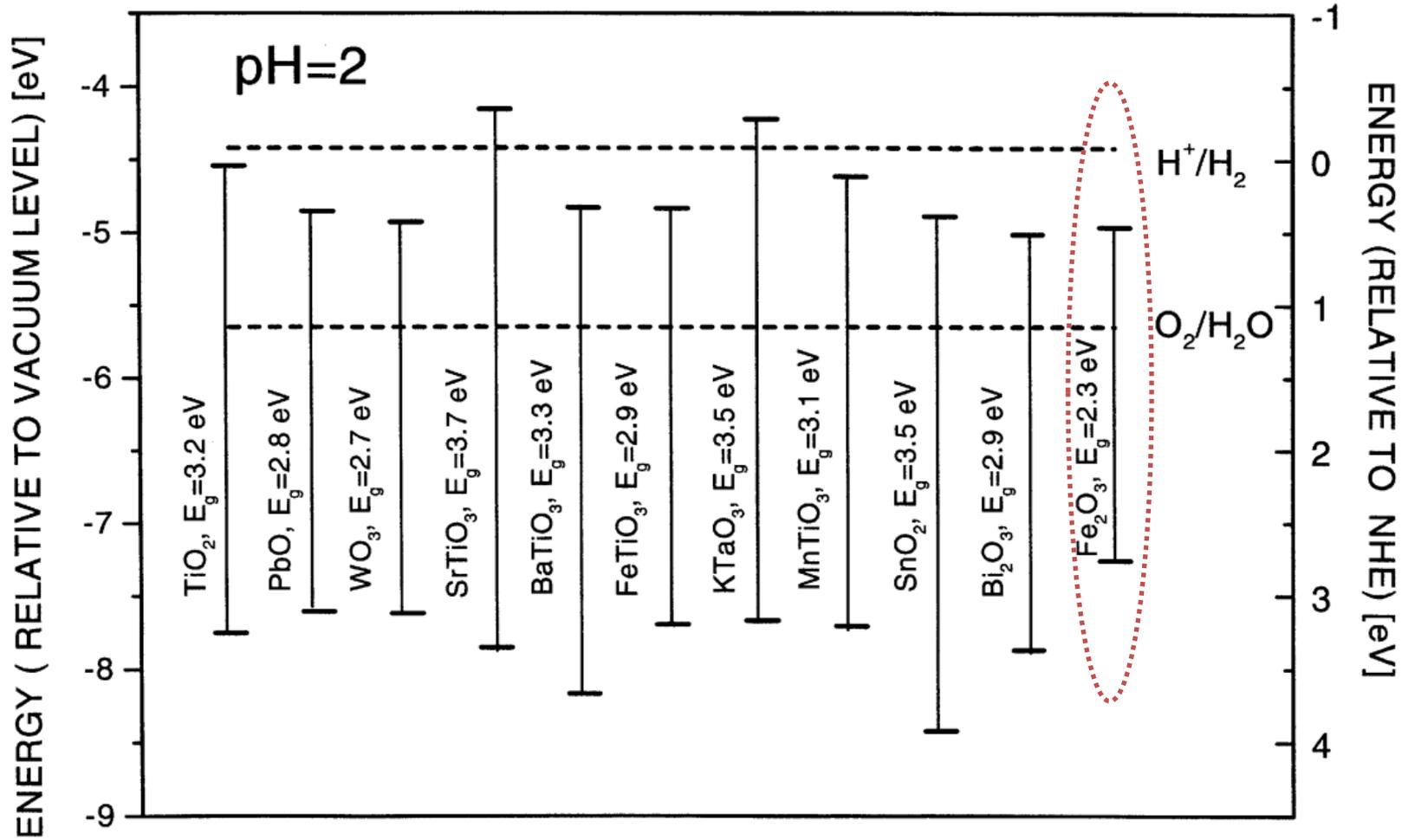
Photoelectrode trade-offs



Bandgap vs. Chemical stability

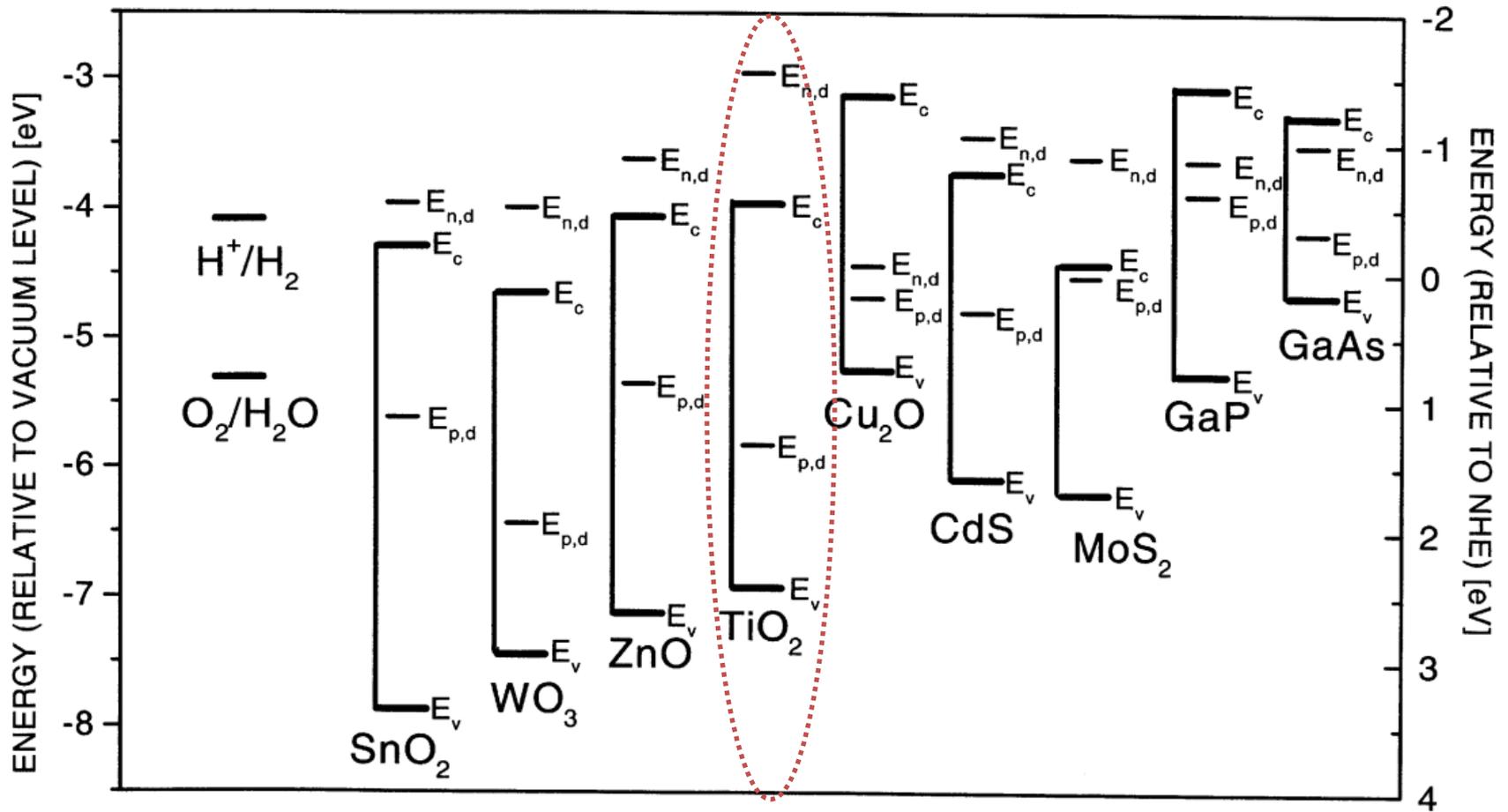


Bandgap vs. Chemical stability



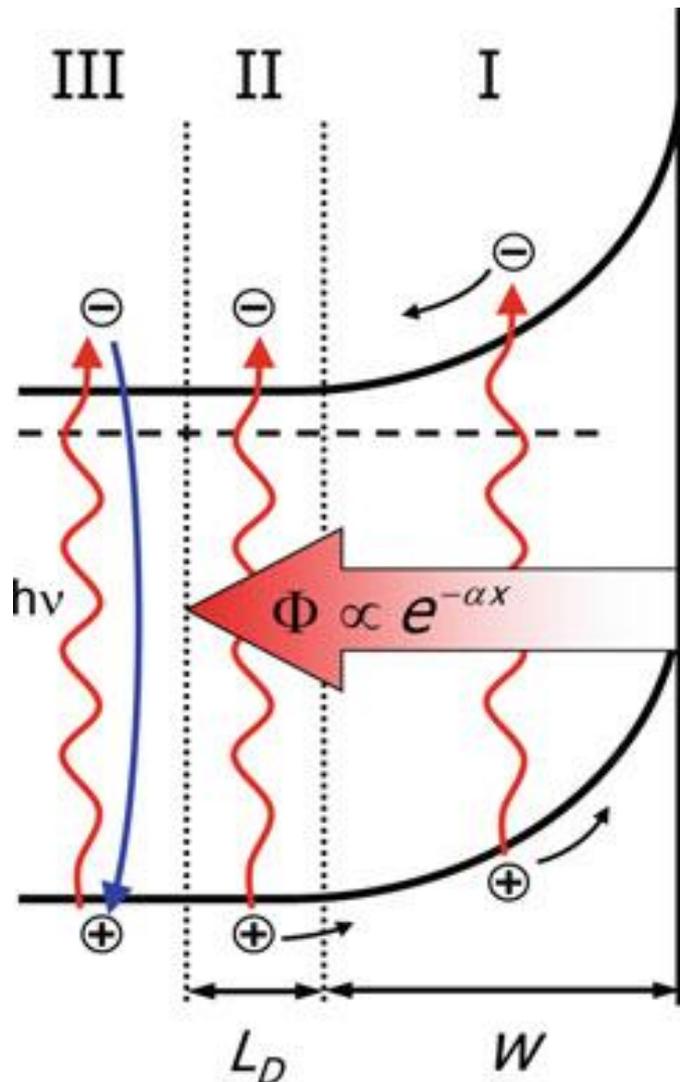
T. Bak, et. al., Int. J. Hyd. Energy, 2002

Bandgap vs. Chemical stability



T. Bak, et. al., Int. J. Hyd. Energy, 2002

Photon collection vs. Charge transport



Region I:

- Absorption
- Charge separation
- Field-assisted transport (drift)

Region II:

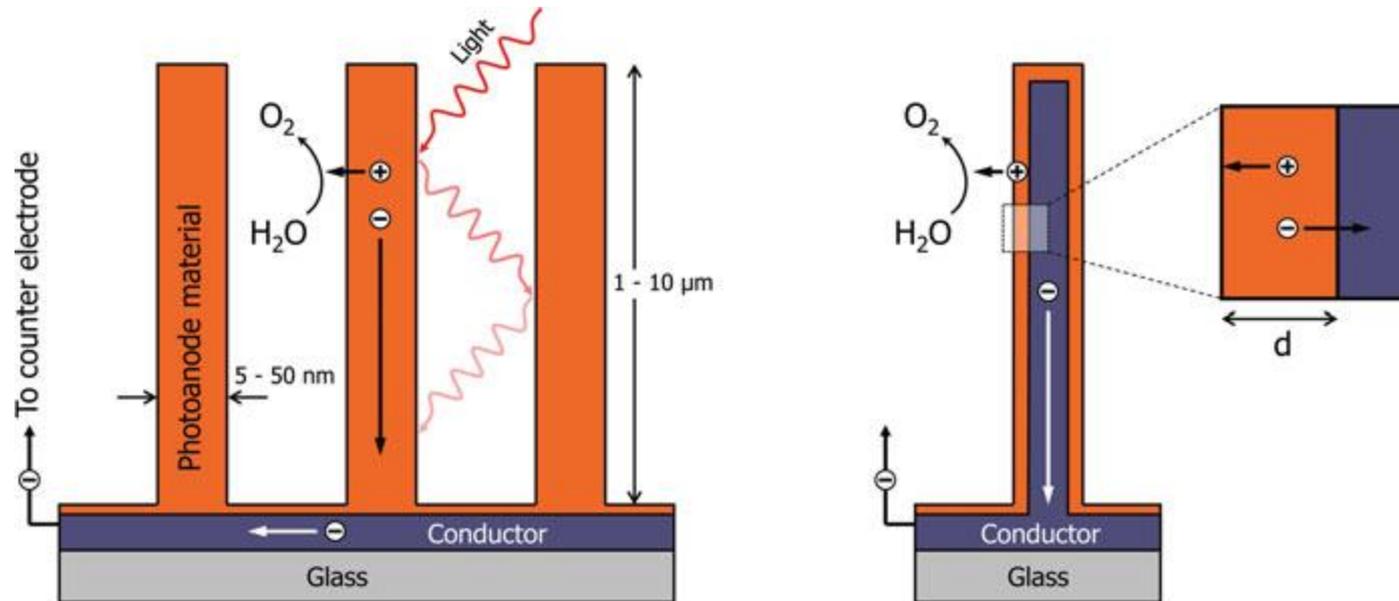
- Absorption
- Transport by diffusion
- Holes are able to reach region I before recombining

Region III:

- Absorption + recombination

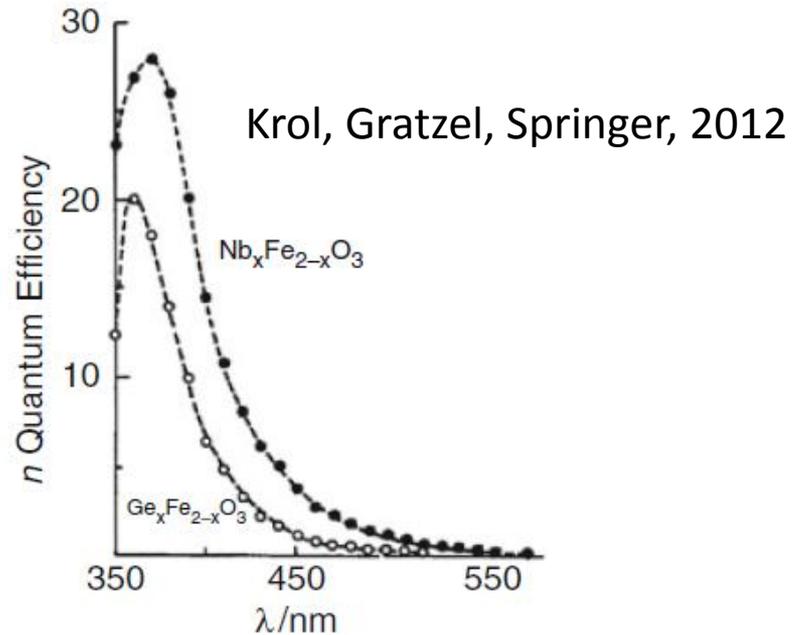
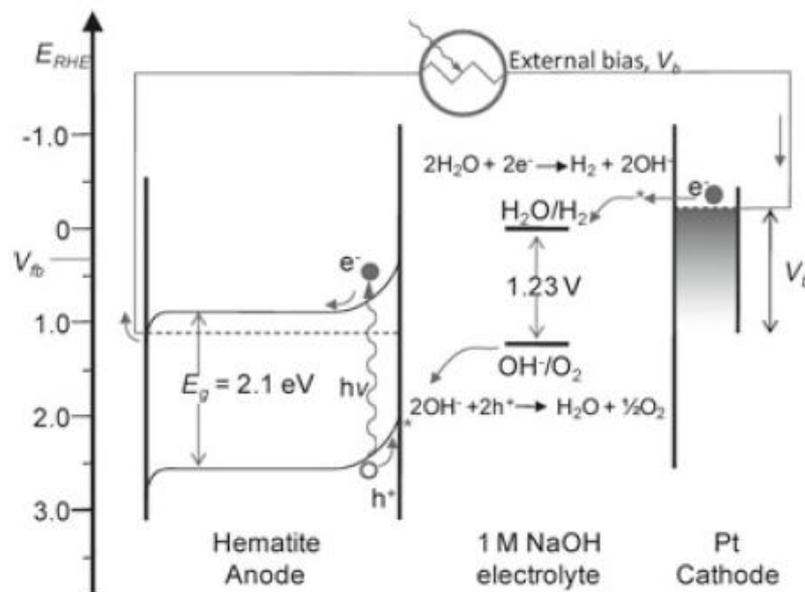
Optimal film thickness: $d \approx \alpha^{-1} \approx W + L_D$

Photon collection vs. Charge transport: Nanostructures



Krol, Gratzel, Springer, 2012

Hematite photoelectrodes for splitting water

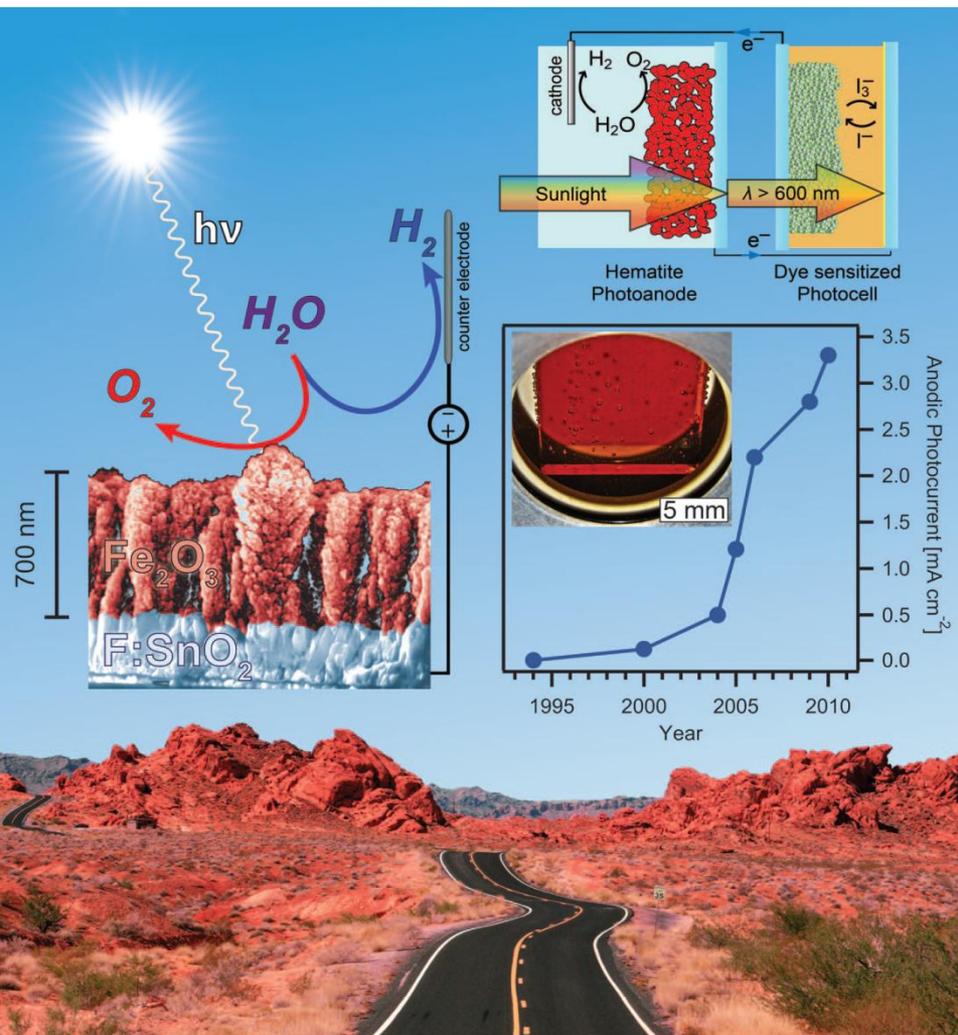


- Based on the bandgap, TiO_2 (anatase, $E_g = 3.2\text{ eV}$) and WO_3 ($E_g = 2.6\text{ eV}$) can at most convert **3.4%** and **10.2%**, respectively, of the sun's energy into hydrogen.
- Iron (III) oxide (Hematite - $\alpha\text{-Fe}_2\text{O}_3$) can potentially convert **16.8%**.

Hematite photoelectrodes for splitting water

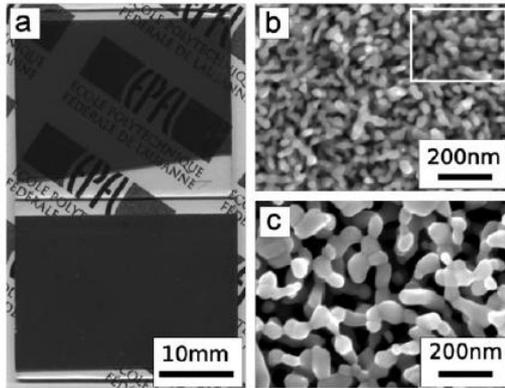
- Challenges - **Solutions**:
 - Flatband potential too low in energy for water reduction – **tandem cells, heterojunctions.**
 - Large overpotential and slow water oxidation kinetics – **co-catalysts like Co and Co-Pi.**
 - Low absorption coefficient, requiring relatively thick films – **nanostuctures, plasmonics.**
 - Poor photogenerated majority carrier conductivity – **nanostuctures.**
 - Short diffusion length of minority – **nanostuctures.**

Hematite nanostructures

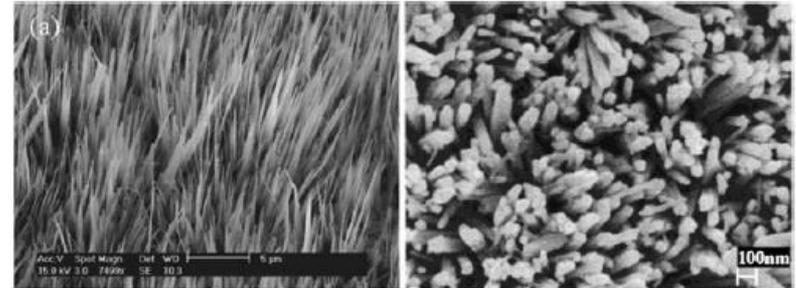


- Methods for preparing hematite nanostructures:
 - Porous thin films from solution based colloidal method.
 - Nanowires
 - Electrochemical anodization
 - Ultrasonic Spray pyrolysis
 - Atmospheric pressure CVD
 - Extremely thin absorbers

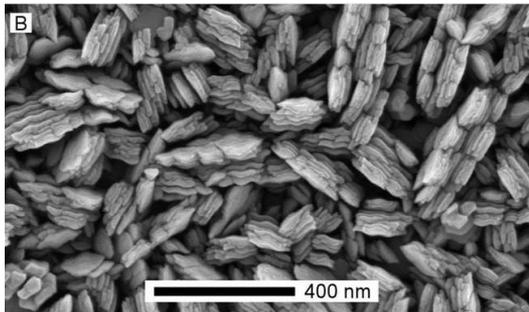
Hematite nanostructures



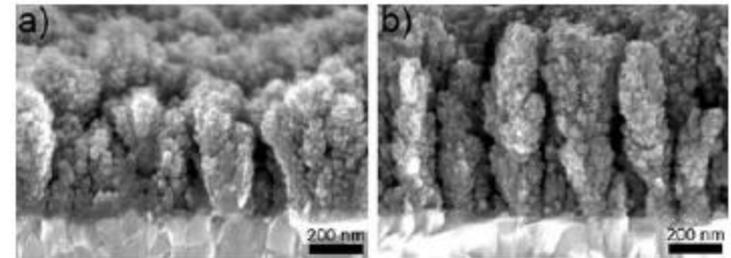
Porous thin films from solution based colloidal method



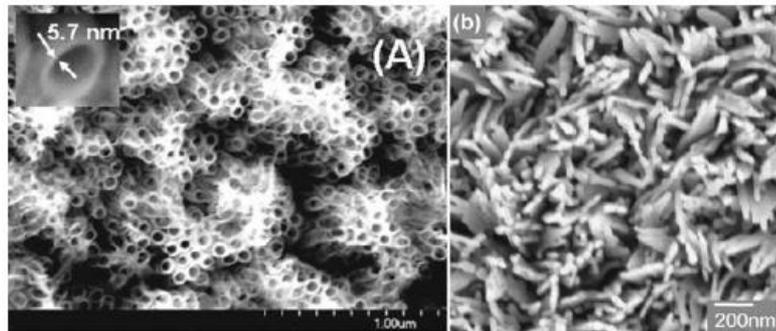
Nanowires



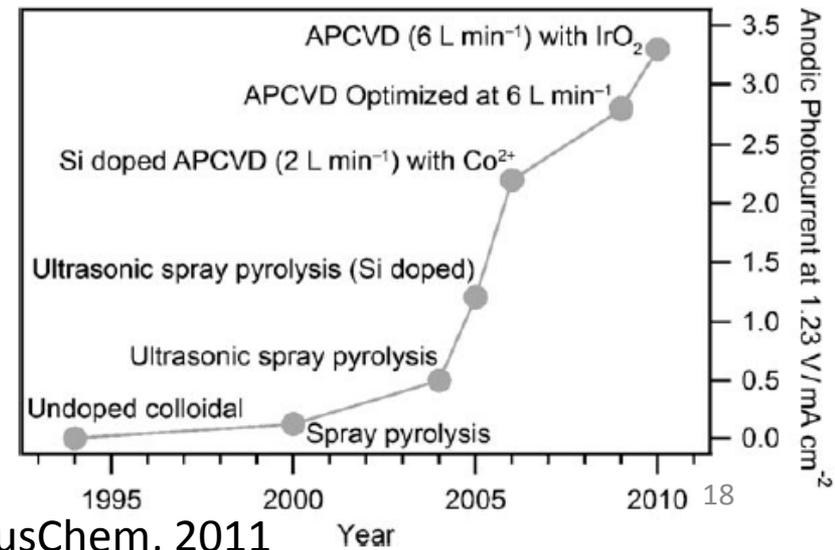
Ultrasonic spray pyrolysis



Atmospheric pressure CVD



Electrochemical anodization



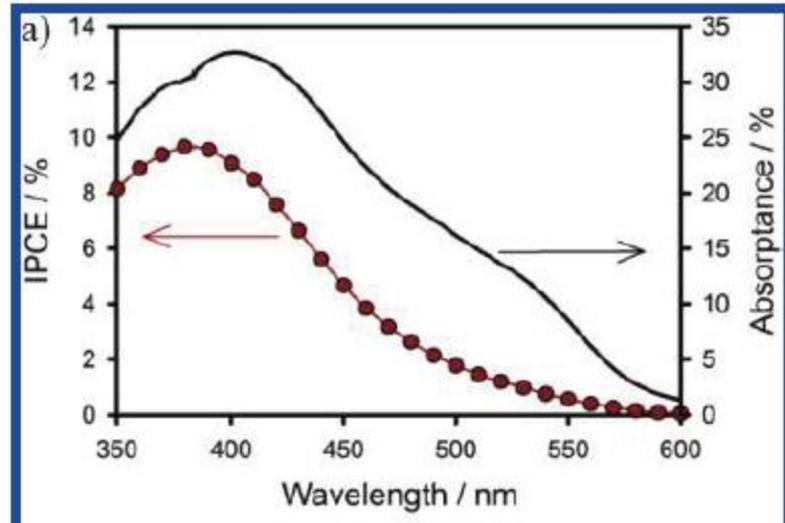
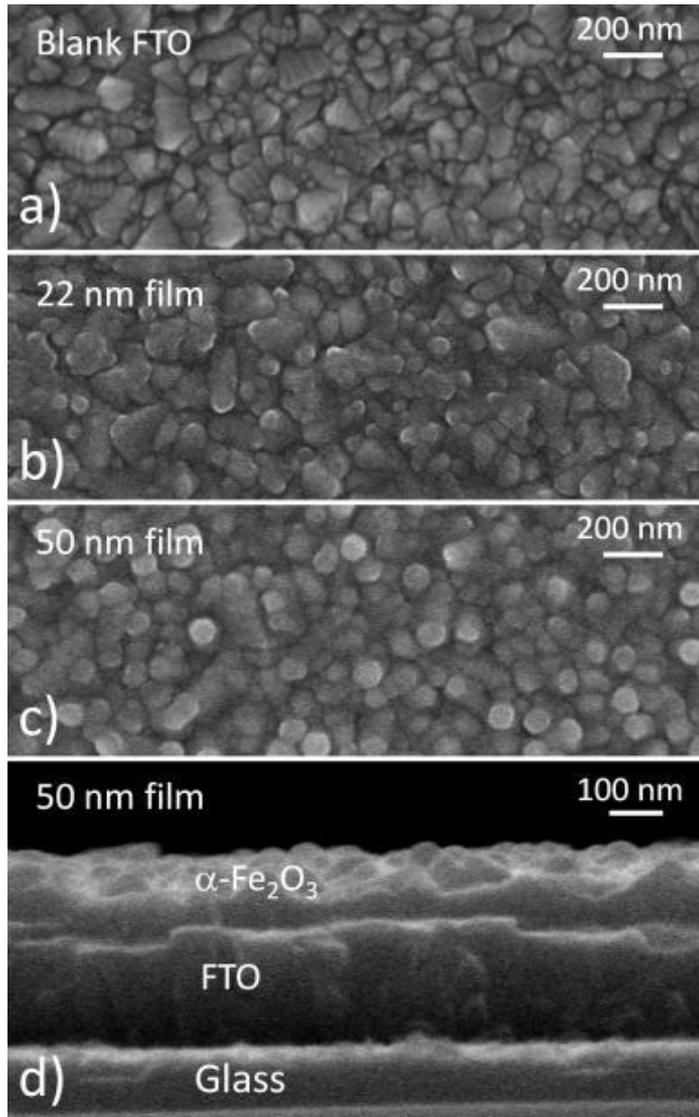
Hematite nanostructures

Table 1. Comparison of hematite photoanode structuring methods

Technique	Feature size	Do- pant	Performance
Single crystal ^[57]	micrometer	Nb	IPCE 37% at 370 nm and 1.23 V _{RHE}
Sintered polycrystalline disk ^[47]	micrometer	Si	IPCE 34% at 400 nm and 1.23 V _{RHE}
Colloidal deposition of porous films ^[88]	25 nm	Ti	2.34 mA cm ⁻² at 1.63 V _{RHE} and AM 1.5 (100 mW cm ⁻²) and IPCE 40% at 400 nm and 1.6 V _{RHE}
Solution-based nanowires ^[27]	50 nm × 500 nm	none	IPCE 7% at 400 nm and 0.9 V _{RHE} (in KI)
Potentiostatic anodization (nanotubes) ^[102]	6 nm × 1 μm	none	Before annealing: None reported After annealing: ^[a] 1.0 mA cm ⁻² at 1.23 V _{RHE} and AM 1.5 (87 mW cm ⁻²)
Electro-deposition ^[28]	20–50 nm	Mo	IPCE 8% at 400 nm and 1.2 V _{RHE}
Ultrasonic spray pyrolysis ^[66,114]	10 nm × 300 nm	Si	1.5 mA cm ⁻² at 1.23 V _{RHE} and AM 1.5 (100 mW cm ⁻²) and IPCE 14% at 400 nm and 1.23 V _{RHE}
Atmospheric pressure CVD ^[77]	5 nm × 800 nm	Si	3.3 mA cm ⁻² at 1.23 V _{RHE} and AM 1.5 (100 mW cm ⁻²) and IPCE 39% at 400 nm (50% at 325 nm and 16% at 550 nm) and 1.23 V _{RHE}
Extremely thin absorber ^[123]	50 nm film	Si	1.3 mA cm ⁻² at 1.23 V _{RHE} and AM 1.5 (100 mW cm ⁻²) and IPCE 26% at 400 nm and 1.43 V _{RHE}

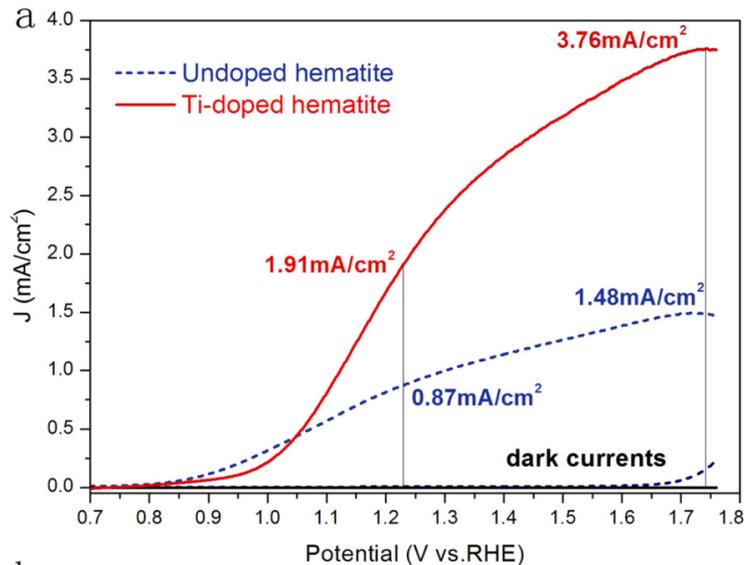
[a] Feature size not reported after annealing.

Hematite Photoelectrodes: Thin films from ALD

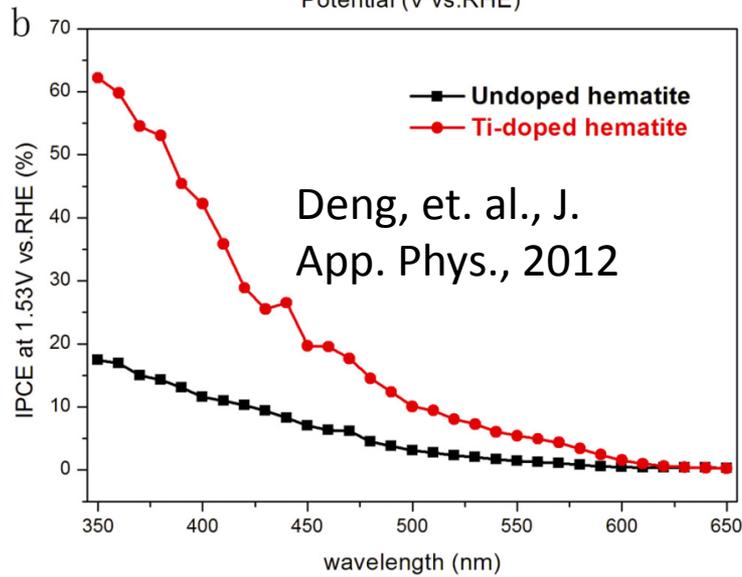


- Optimal thickness was found to be 20 nm.
- Efficiency is low due to mid-gap traps and low hole mobility.

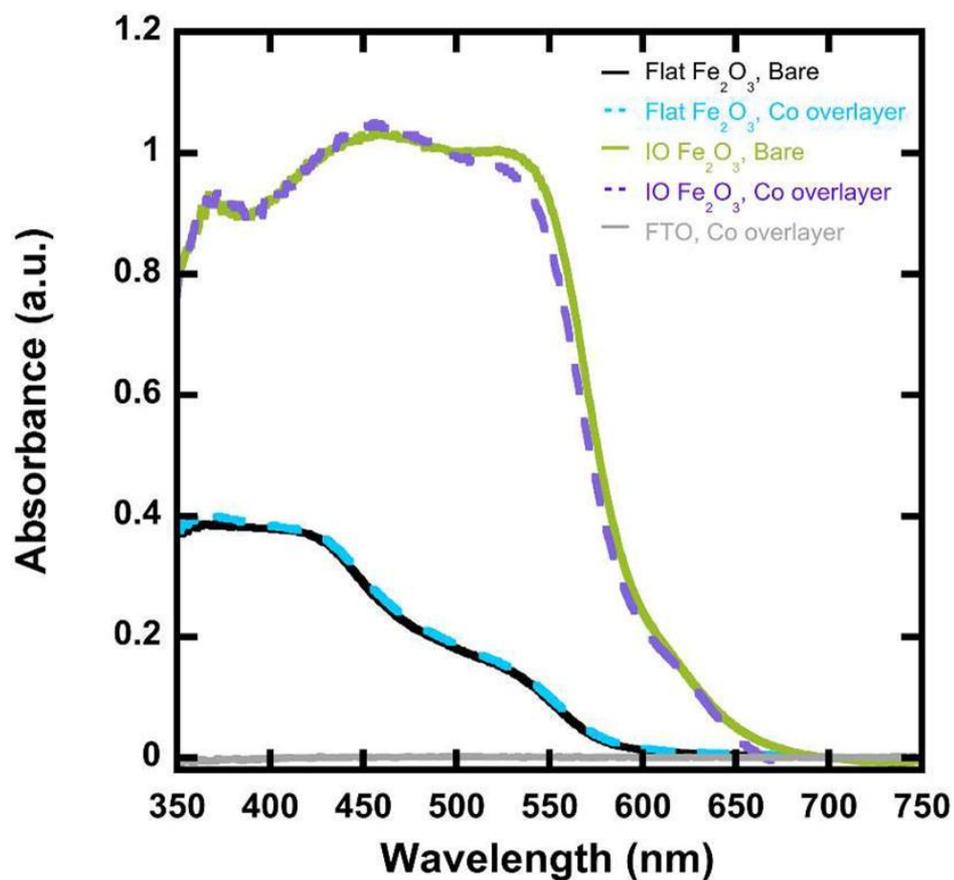
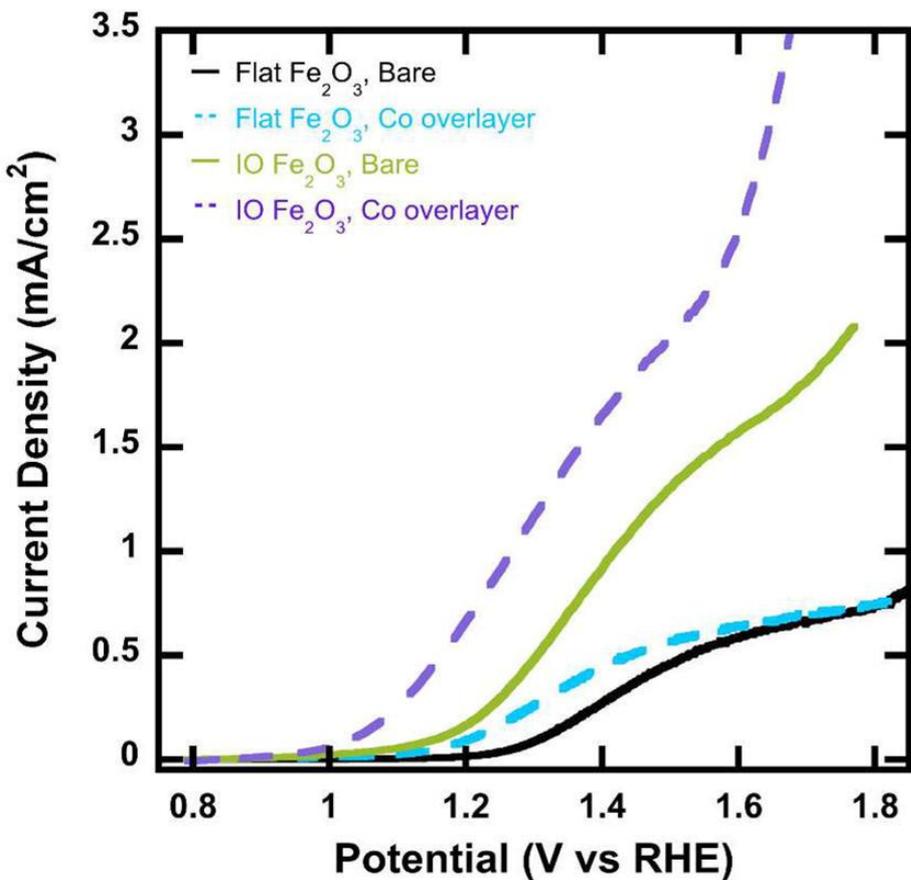
Hematite Photoelectrodes: Doped Hematite thin films



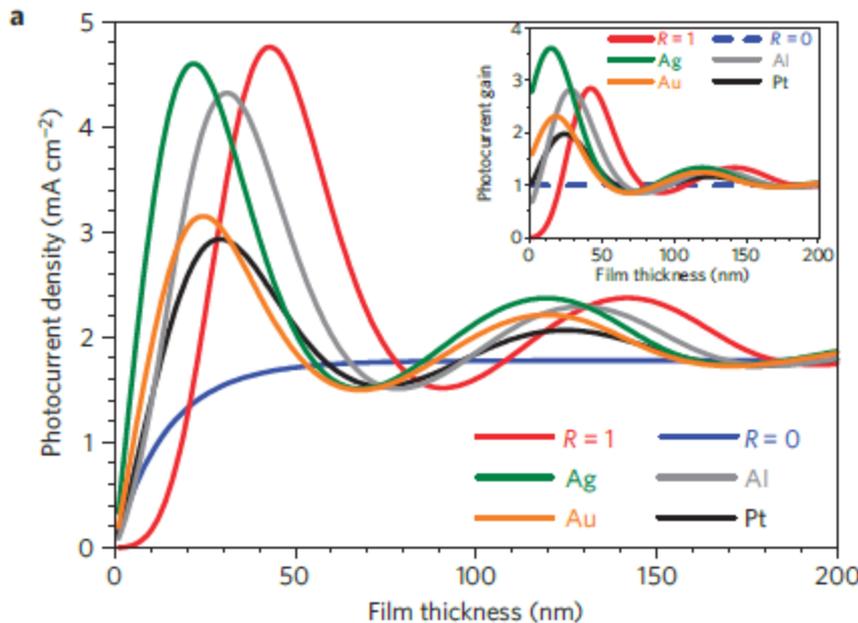
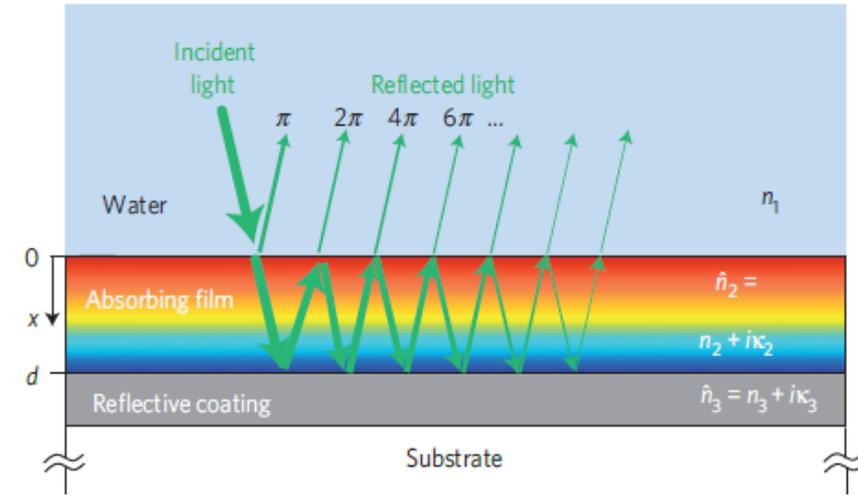
- Si, Ti and Zr doping have been shown to improve the photocurrent density.



Hematite photoelectrodes: Co-catalyst and nano-scaffolds

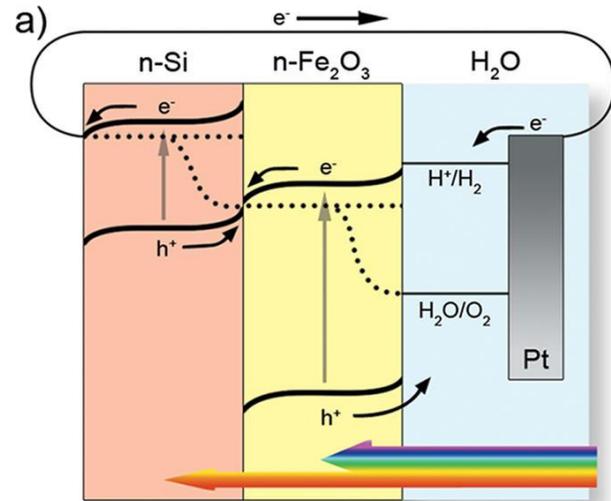


Hematite photoelectrodes: Resonant light trapping

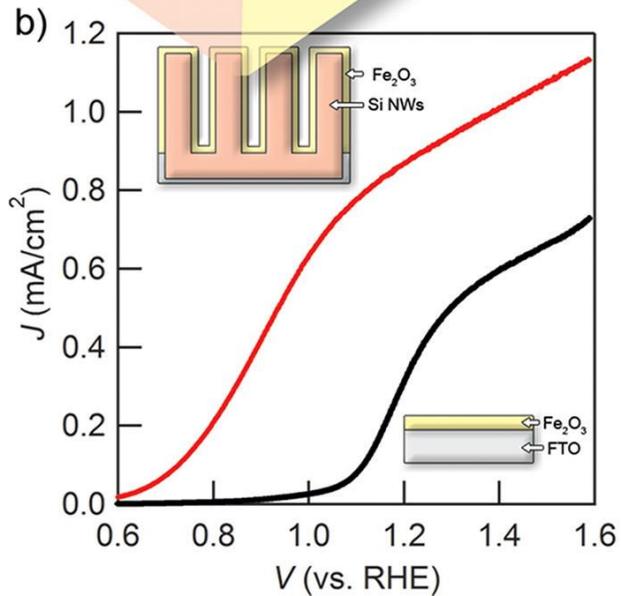


- Charge separation and collection yield of photogenerated holes in Ti doped hematite increases with decreasing thickness.
- Absorption decreases with decreasing thickness. Solution – optical cavity.

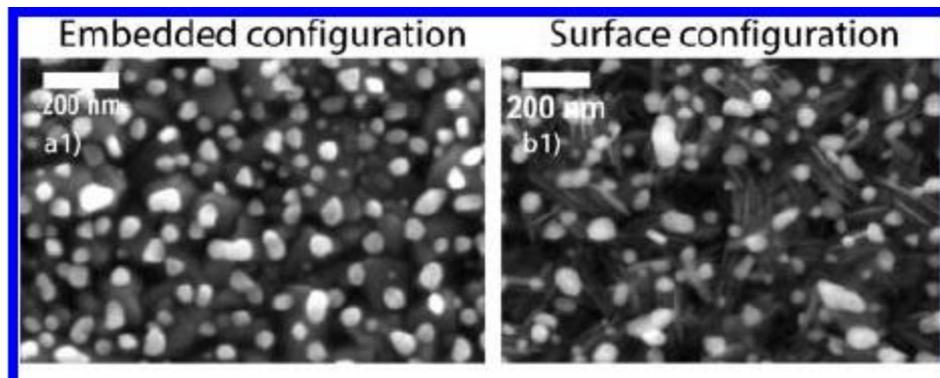
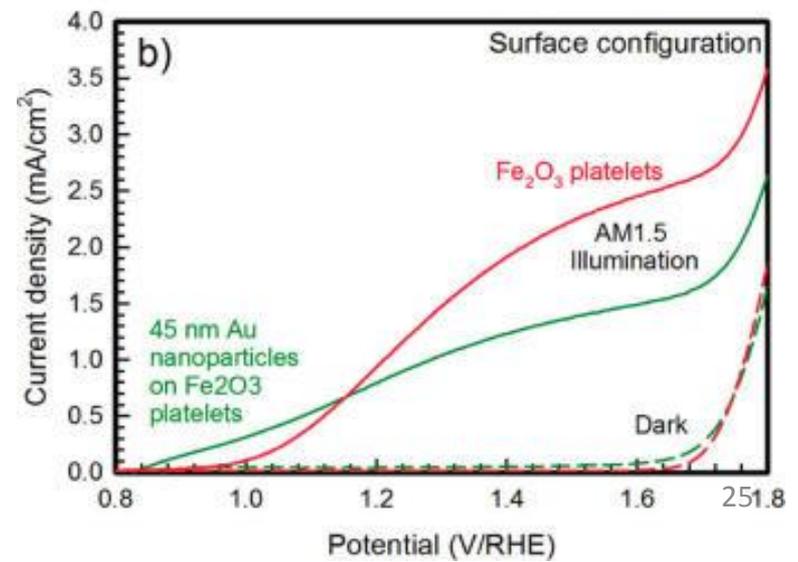
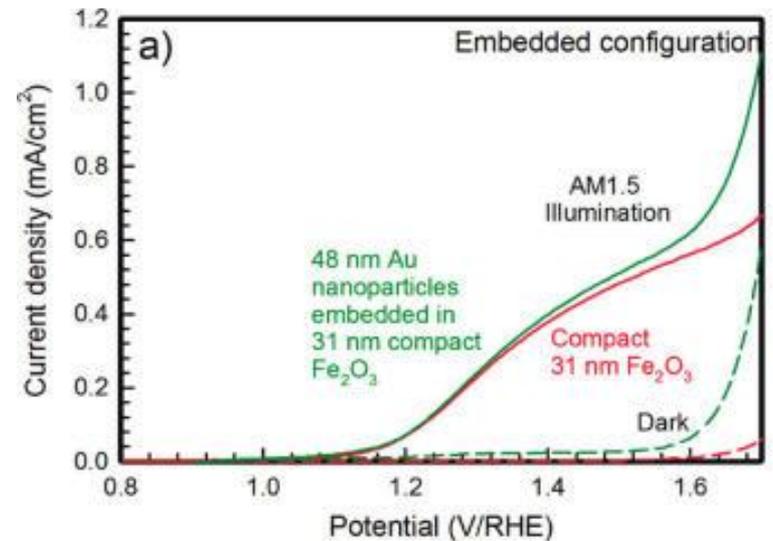
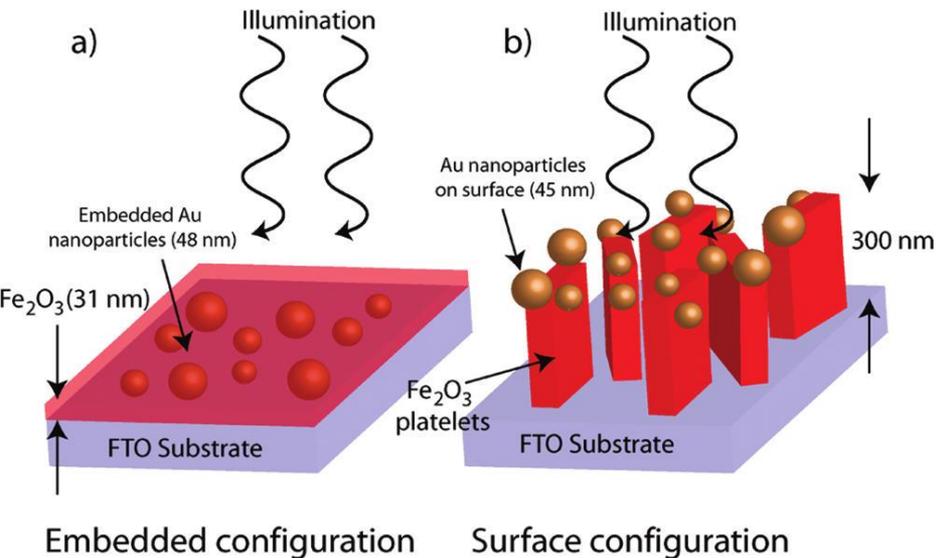
Hematite photoelectrodes: Heterojunctions



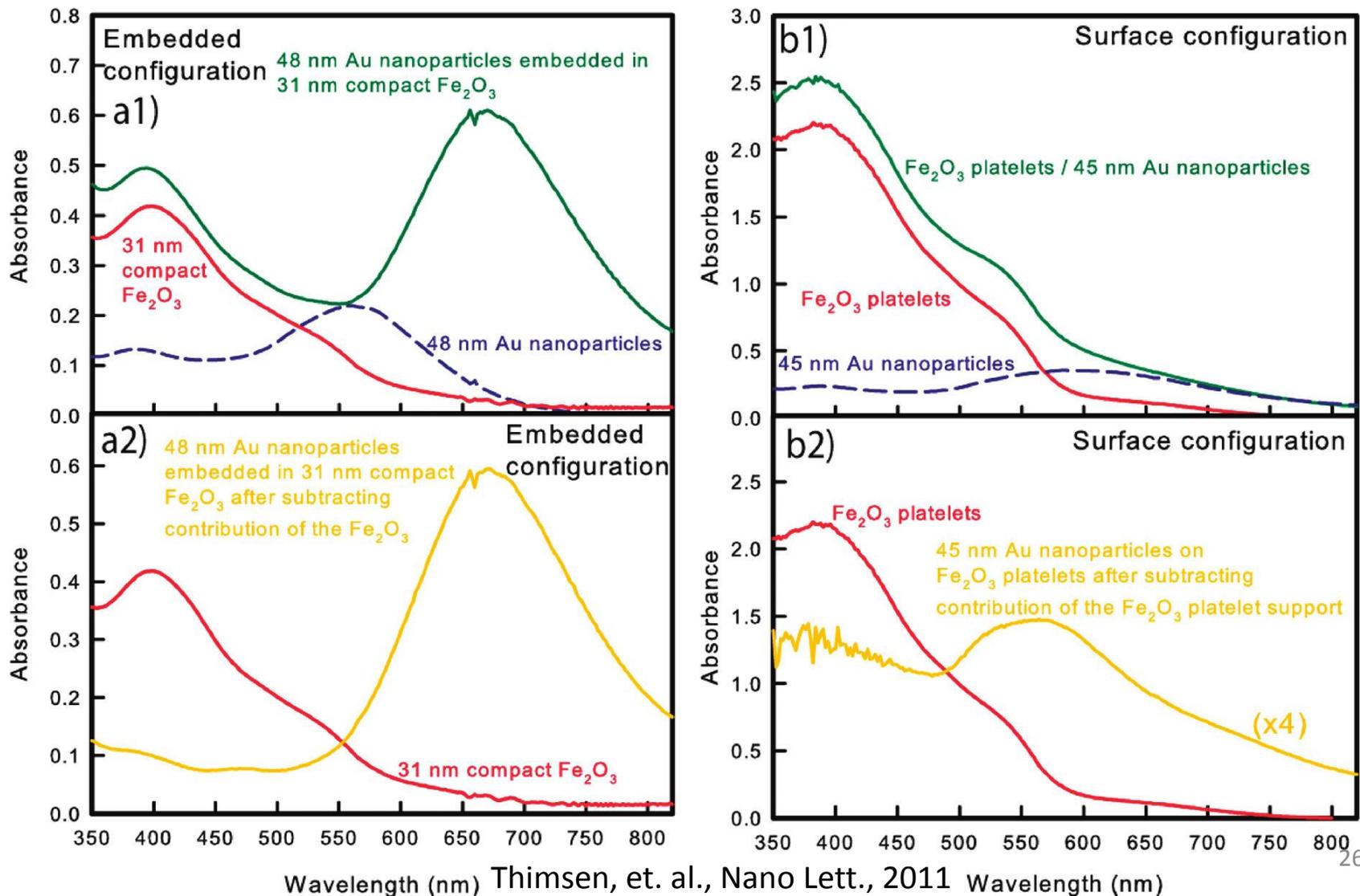
- Onset potential is 0.6 V_{RHE}
- Fig b - Red – nanowire;
Black – planar



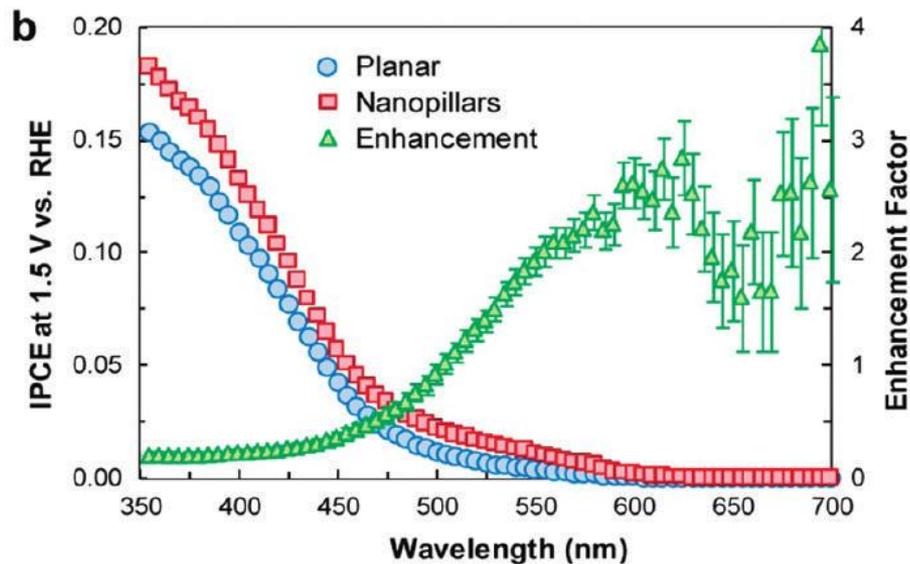
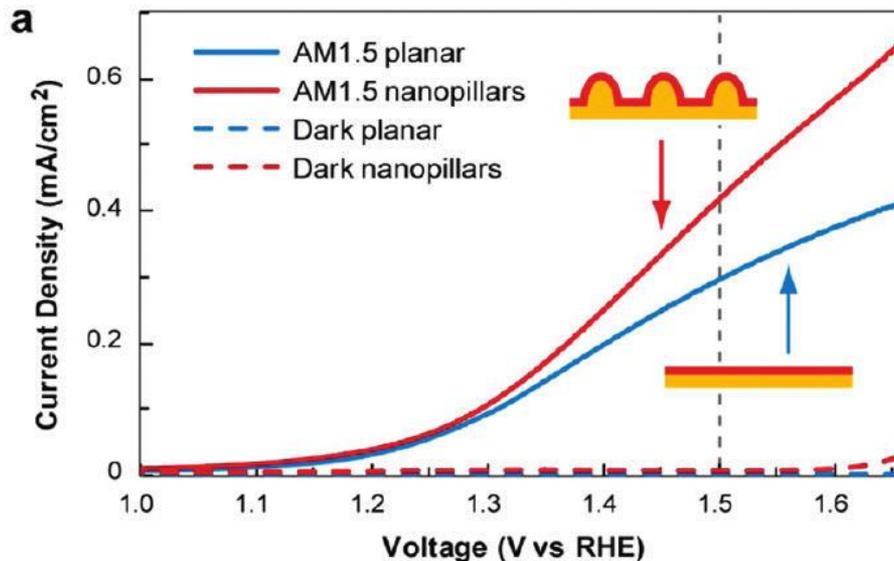
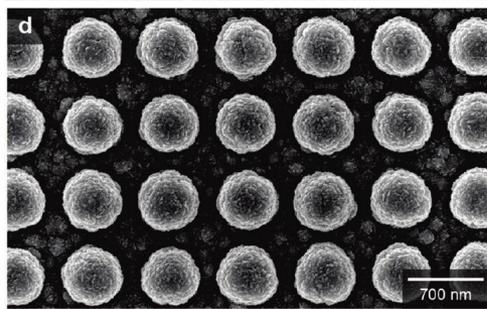
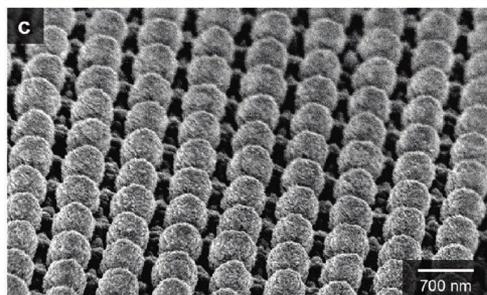
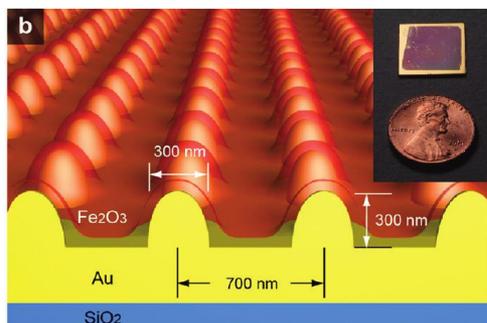
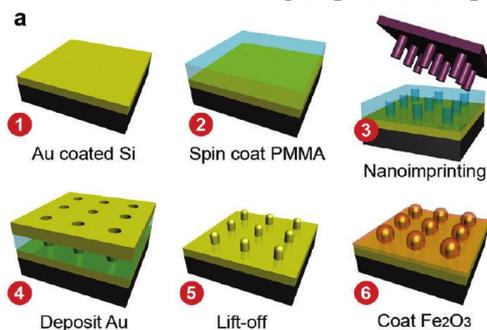
Plasmonic Photoelectrodes: Au-Hematite



Plasmonic Photoelectrodes: Au-Hematite

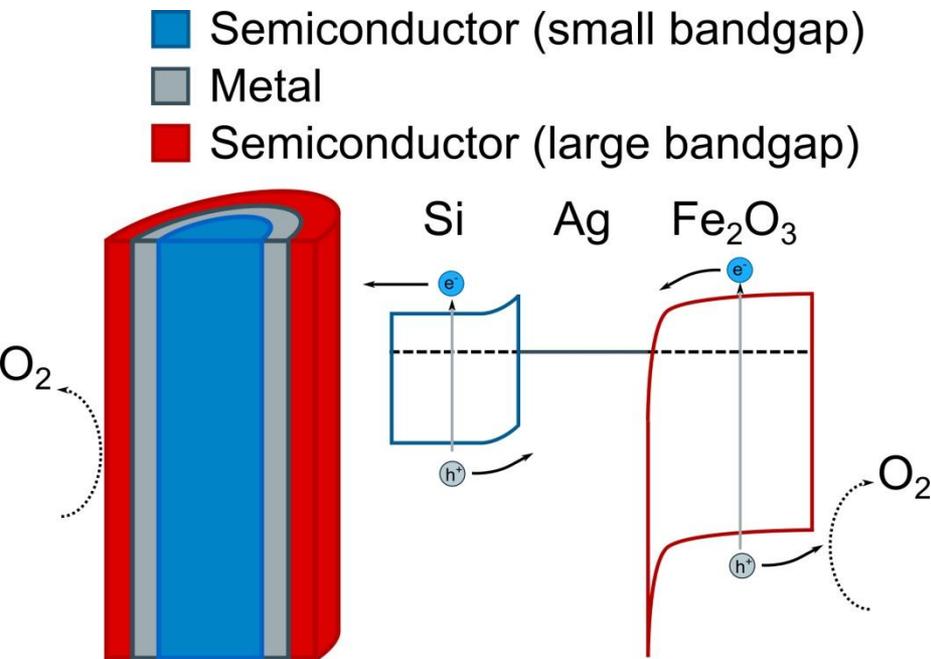


Plasmonic Photoelectrodes: Au-Hematite



Gao, et.
al., ACS
Nano,
2012.

Plasmonic Photoelectrodes: Core-multishell nanowires



- Flatband potential too low in energy for water reduction – **Si core provides the required increase in energy.**
- Large overpotential and slow water oxidation kinetics – **Hot electrons from the metal inner shell could potentially help.**
- Low absorption coefficient, requiring relatively thick films – **Si core, plasmonic resonances and nanowire geometry.**
- Poor photogenerated majority carrier conductivity – **metal shell, thin hematite shells.**
- Short diffusion length of minority – **nanowire geometry, metal inner shell.**

Conclusion

- Hematite is chemically stable in electrolytes and has the right bandgap to function as a photoelectrode with a potential maximum efficiency of 16.8%.
- Poor absorption, high recombination, low conductivity limits its performance
- Many nanostructures, doping, co-catalysts and growth methodologies have been studied to improve material quality and efficiency.
- More recently, plasmonic enhancement of hematite photoelectrodes has been explored. These studies indicate that carefully designed plasmonic photoelectrodes could lead to higher efficiency.
- In this regard, core-multishell nanowire structures could lead to significantly improved efficiencies.

Thank you!

Questions?

Appendix

